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APPLICATION NO.	N NO. FILING DATE FIRST NAMED INVENTOR		ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/816,294	03/31/2004	David J. Seagle	K35R1871	8577	
35219 75	90 11/07/2006		EXAMINER		
WESTERN D ATTN: SANDE	IGITAL TECHNOLOG	CHEN, TIANJIE			
20511 LAKE F		ART UNIT	PAPER NUMBER		
E-118G		2627			
LAKE FOREST	Γ, CA 92630	DATE MAILED: 11/07/2006			

Please find below and/or attached an Office communication concerning this application or proceeding.

			Application N	о.	Applicant(s)				
Office Action Summary		10/816,294		SEAGLE, DAVID J.					
		Examiner		Art Unit					
			Tianjie Chen		2627				
Period fo	The MAILING DATE of this commu r Reply	nication app	ears on the cov	er sheet with the c	orrespondence ac	idress			
WHIC - Exter after: - If NO - Failui Any r	DRTENED STATUTORY PERIOD IN THE NEW PERIOD IN TH	MAILING DA s of 37 CFR 1.13 munication. tatutory period wi y will, by statute,	ATE OF THIS (6(a). In no event, ho ill apply and will expi- cause the application	COMMUNICATION wever, may a reply be tirr re SIX (6) MONTHS from to become ABANDONE	l. nely filed the mailing date of this o D (35 Ú.S.C. § 133).				
Status									
1)	Responsive to communication(s) fil	ed on <u>25 Se</u>	eptember 2006						
	This action is FINAL .		action is non-f						
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is								
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.								
Dispositi	on of Claims				٠				
4)🖂	Claim(s) 1-45 is/are pending in the	application.							
	4a) Of the above claim(s) <u>40-44</u> is/are withdrawn from consideration.								
5)🖂	Claim(s) <u>1-39</u> is/are allowed.				·				
6)⊠	6)⊠ Claim(s) <u>45</u> is/are rejected.								
7)	Claim(s) is/are objected to.								
8)[Claim(s) are subject to restr	iction and/or	election requi	rement.					
Applicati	on Papers								
9)[The specification is objected to by tl	ne Examiner	r.						
10)[The drawing(s) filed on is/are	e: a) <u>□</u> acce	epted or b)⊡ c	bjected to by the I	Examiner.				
	Applicant may not request that any obje	ection to the o	drawing(s) be he	ld in abeyance. See	e 37 CFR 1.85(a).				
	Replacement drawing sheet(s) including	g the correcti	ion is required if	the drawing(s) is ob	jected to. See 37 C	FR 1.121(d).			
11)[The oath or declaration is objected	to by the Ex	aminer. Note tl	ne attached Office	Action or form P	ΓΟ-152.			
Priority u	ınder 35 U.S.C. § 119								
-	Acknowledgment is made of a claim	for foreign	priority under	35 U.S.C. § 119(a))-(d) or (f).				
a)[☐ All b)☐ Some * c)☐ None of:								
	1. Certified copies of the priority documents have been received.2. Certified copies of the priority documents have been received in Application No								
				• •		l Stage			
	 Copies of the certified copies application from the Internati 	•	-		eu III ulis Ivauoriai	Stage			
* 5	See the attached detailed Office acti		•		ed ·				
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Attachmen	t(s)		•						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)									
2) Notic	e of Draftsperson's Patent Drawing Review (e. [Paper No(s)/Mail Date					
	nation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	•	5) Notice of Informal Patent Application 6) Other:						

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Non-Final Rejection

Election/Restrictions

1. Applicant's election without traverse of Group I claims 1-39 and 45 in the reply filed on 09/25/2006 is acknowledged.

Specification

- 2. The disclosure is objected to because of the following informalities:
 - In [002], line7; the half of the quotation mark should be deleted.

Appropriate correction is required.

Claim Objections

- 3. Claim 14 is objected to because of the following informalities:
 - In claim 14, line 2; "maganese" should be change to --manganese--.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claim 45 is rejected under 35 U.S.C. 103(a) as being unpatentable over Hasagawa et al (US 2004/0106012).

Claim 45, Hasagawa et al shows a magnetoresistive read head in Fig. 1 including: a first shield layer 20 ([0081]); a first gap layer 21 over the first shield layer; a spin-valve stack over the first gap layer, the spin-valve stack including: a seed layer 22 over the first gap layer; an antiferromagnetic layer 23 over the seed layer; a pinned

layer 24 over the antiferromagnetic layer; and a free layer 26 over the pinned layer and over a first portion D of the antiferromagnetic layer; and a bias structure 35 over a second portion C of the antiferromagnetic layer.

Hasagawa's device has same layer structure as Applicant's structure as described; therefore, Hasagawa's device should have same magnetic potential as Applicant's device, i.e. the seed layer has a magnetostatic potential substantially equal to the magnetostatic potential of the first shield layer.

Allowable Subject Matter

5. Claims 1-39 allowed.

The following is an examiner's statement of reasons for allowance:

• With regard to independent claim 1, as the closest reference on record, Hasagawa et al (US 2004/0106012) shows a magnetoresistive read sensor in Fig. 1 including: a first shield layer, a first gap layer over the first shield layer, a spin-valve stack over the first gap layer, the spin-valve stack including: a seed layer over the first gap layer, an antiferromagnetic layer over the seed layer; and a free layer over a first portion of the antiferromagnetic layer; and a bias structure adjacent to the free layer, the bias structure located over a second portion of the ferromagnetic layer and isolated from the seed layer by the second portion; but fails to show that at least a portion of the seed layer including a soft-magnetic material NiFeCr; an antiferromagnetic layer over the seed layer, the antiferromagnetic layer magnetically decoupled from the seed layer. Applicant asserts in p. 6 that in his invention the read sensor 10 comprises an exchange break layer 84 between the antiferromagnetic layer 44 and the seed layer 42, as schematically illustrated by Figure 2, which "magnetically decouples the

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antiferromagnetic layer 44 from the seed layer 42 by "breaking" or reducing the exchange coupling between the two layers. Hasagawa et al does not show the exchange break layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

The prior art made of record in PTO-892 Form and not relied upon is considered pertinent to applicant's disclosure.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tianjie Chen whose telephone number is 571 272 7570. The examiner can normally be reached on 8:00-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nguyen Hoa can be reached on 571 272 7579. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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TIANJIE CHEN
PRIMARY EXAMINEI